

ICMAP 2018

The 7th International Conference on Microelectronics and Plasma Technology
Joint International Conference on ICMAP 2018, APCPST 2018, and ISPB 2018
July 24–28, 2018 / Songdo ConvensiA, Incheon, Korea

Poster Session III

Date / Time July 27 (Fri.), 2018 / 17:30-19:00

Place Room F (#117~118)

FP-001

Ti_xSi_{1-x}O₂ Deposited by Plasma-Enhanced Atomic Layer Deposition for Spacer Application

Sanghun Lee¹, Woo-Jae Lee², Wontae Noh³, Satoko Gatineau³, Se-Hun Kwon², and Hyungjun Kim¹

¹Yonsei Univ., Korea, ²Pusan Nat'l Univ., Korea, ³Air Liquide Lab., Korea

FP-002

Tungsten Thin Films Deposited by Plasma-Enhanced Atomic Layer Deposition with Tungsten Chloride Precursor

Seunggi Seo¹, Yujin Lee¹, Il-Kwon Oh¹, Bonggeun Shong², and Hyungjun Kim¹

¹Yonsei Univ., Korea, ²Hongik Univ., Korea

FP-003

A Study on the Passivation Characteristics According to the RF-Power Variable of Tunnel Oxide Layer Using N₂O Gas

Sehyeon Kim, Sanguk Han, Sooyoung Park, Geonju Yoon, Youngseok Lee, Sangho Kim, Seongho Jeon, Donggi Shin, and Junsin Yi

Sungkyunkwan Univ., Korea

FP-004

Synthesis of MoS₂ by Plasma Enhanced Atomic Layer Deposition for Gas Sensor

Youngjun Kim, Minjoo Lee, Kyung Yong Ko, Jusang Park, and Hyungjun Kim

Yonsei Univ., Korea

FP-005

The Role of Discharge in Plasma Assisted Atomic Layer Deposition Technique

Zhongwei Liu, Zhengduo Wang, Lijun Sang, and Qiang Chen

Beijing Inst. of Graphic Communication, China

FP-006

High-Quality Cobalt Thin Film Deposited by Using Very High Frequency Plasma-Enhanced Atomic Layer Deposition

Won-kyun Yeom and Geun-Young Yeom

Sungkyunkwan Univ., Korea

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July 24–28, 2018 / Songdo ConvensiA, Incheon, Korea

FP-007

On the Carrier Concentration of Nanocrystalline Si:H Films Made by Inductively Coupled Plasma with Low-Inductance Antenna

H.H. Yang and Jyh-Shiarn Cherng
Ming Chi Univ. of Tech., Taiwan

FP-008

Preparation of Diamond-Like Carbon Films Using a Cathode Localized Glow Discharge under Sub-Atmospheric Pressure Excited by a High-Repetition Nanosecond Pulsed Voltage Application

Yusuke Kikuchi¹, Takuya Maegawa¹, Ryo Hirano¹, Akira Otsubo², Yoshimi Nishimura², Masayoshi Nagata¹, and Mitsuyasu Yatsuzuka¹
¹*Univ. of Hyogo, Japan*, ²*Kurita Seisakusyo Co. Ltd., Japan*

FP-009

Al₂O₃-CxHy Multilayer Thin Films Manufactured by Plasma-Enhanced Atomic Layer Deposition and Plasma Polymerization for Moisture Barrier Film

Jin Young Lee¹, Woo Seok Kang², Dae Woong Kim², Jae Ok Lee², Min Hur², and Gon Ho Kim¹
¹*Seoul Nat'l Univ., Korea*, ²*KIMM, Korea*

FP-010

Low Dielectric Constant Plasma Polymerized SiCOH Film Deposited from Tetrakis(trimethylsilyloxy) Silane as a Flexible Insulator

Hyuna Lim¹, Wonjin Ban¹, Sungyool Kwon¹, Yoonsoo Park¹, Younghyun Kim¹, Seonhee Jang², and Donggeun Jung¹
¹*Sungkyunkwan Univ., Korea*, ²*Univ. of Louisiana at Lafayette, USA*

FP-011

Plasma Copolymerization of Ultra-Low Dielectric Constant SiCOH Films Using Octamethylcyclotetrasiloxane and Tetraethyl Orthosilicate Precursors

Yoonsoo Park, Sungyool Kwon, Wonjin Ban, Hyuna Lim, and Donggeun Jung
Sungkyunkwan Univ., Korea

FP-012

Characteristic Analysis of Optimized SiO₂ / SiON_x Stack Passivation Layer and Study on Application of High Efficiency N-Type c-Si Solar Cell

Geonju Yoon, Sanguk Han, Sooyoung Park, Sehyeon Kim, Youngseok Lee, Sangho Kim, Seongho Jeon, Donggi Shin, and Junsin Yi
Sungkyunkwan Univ., Korea

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July 24-28, 2018 / Songdo ConvensiA, Incheon, Korea

FP-013

Improvement of Memory Characteristics of MIS-NVM Device Using Hydrogenated Gate Oxide

Sehyeon Kim, Geonju Yoon, Jungsoo Kim, Sangho Kim, Youngseok Lee, Seongho Jeon, and Donggi Shin

Sungkyunkwan Univ., Korea

FP-014

Development of the Virtual Metrology for the Nitride Thickness in Multi-Layer Plasma-Enhanced Chemical Vapor Deposition Using Plasma-Information Variables

Hyun-Joon Roh¹, Sangwon Ryu¹, Yunchang Jang¹, Nam-Kyun Kim¹, Younggil Jin², Seolhye Park², and Gon-Ho Kim¹

¹Seoul Nat'l Univ., Korea, ²Samsung Display Co., Ltd., Korea

FP-015

Fluid Simulation on Plasma Characteristics of RF Capacitively Coupled Plasma Sustained in SiH₄/N₂/O₂ and Ar/SiH₄/N₂O

Wen-Zhu Jia, Yuan-Hong Song, and You-Nian Wang

Dalian Univ. of Tech., China

FP-016

Residual Gas Composition during Diamond Deposition with a New Developed Microwave Surface Wave Plasma Source

Hyun Jong You, Oleksii Girka, Seung Whan Lee, and Seung Pyo Hong

NFRI, Korea

FP-017

Flexibility, Validity and Susceptibility of Cylindrical Langmuir Probes for CubeSat and Pico-Satellite to Characterize Ionosphere and Thermosphere Plasma

Shankar Bhattarai

Tribhuvan Univ., Nepal

FP-018

CubeSat with Cylindrical Langmuir Probes to Characterize Ionosphere and Thermosphere Plasma

Shankar Bhattarai

Tribhuvan Univ., Nepal

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The 7th International Conference on Microelectronics and Plasma Technology
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July 24-28, 2018 / Songdo ConvensiA, Incheon, Korea

FP-019

Research and Patent Trend Analysis of Plasma Technology for Next-Generation Semiconductor Manufacturing Process and Manufacturing Equipment Development

Ki-hwan Cho
NFRI, Korea

FP-020

Experimental and Numerical Analysis of Nanoscale Particle Created during PECVD of Amorphous Carbon Layer

Dongbin Kim¹, Seungki Chae¹, Sang-Woo Kang², and Taesung Kim¹
¹*Sungkyunkwan Univ, Korea*, ²*Univ. of Science and Tech., Korea*

FP-021

Introduction of Thickness Monitoring Sensor, SR as Integrated Metrology in PECVD System

Chul Lee, Hyeju Hwang, Sangho Park, Kwangjung Son, Keunhyeok Lee, Hyuncheol Wang, and Nae Il Lee
Wonik IPS, Korea

FP-022

Use of Laser for Characterizing Ion Density and Sheath of N₂ Plasma

Jinsu Jung and Byungwhan Kim
Sejong Univ., Korea

FP-023

The Comparison of End-Point Detection between Optical Spectroscopy and Residual Gas Analysis in Silicon Etching in NF₃/Ar Plasma

Heetae Kwon, Hwanhee Lee, Giwon Shin, Woojae Kim, and Gichung Kwon
Kwangwoon Univ., Korea

FP-024

A Study on the Prediction of Density from OES(Optical Emission Spectroscopy) Data Using Machine Learning Algorithm

Jung Ho Song, Jong Sik Kim, Dae Chul Kim, Yong Hyun Kim, Duk Sun Han, and Young Woo Kim
NFRI, Korea

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The 7th International Conference on Microelectronics and Plasma Technology
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July 24–28, 2018 / Songdo ConvensiA, Incheon, Korea

FP-025

Incoherent Laser Thomson Scattering Diagnostic for Pulsed Streamer Discharge

Ryo Fujita¹, Kyohei Eguchi¹, Douyan Wang¹, Kentaro Tomita², and Takao Namihira¹

¹Kumamoto Univ., Japan, ²Kyushu Univ., Japan

FP-026

Plasma Diagnosis by Electrical Method

Gi-Chung Kwon, Gi Won Shin, Woo Jae Kim, Hee Tae Kwon, and Hwan Hee Lee

Kwangwoon Univ., Korea

FP-027

Experimental Study on Arcing Detection Technology in PECVD Process

Hye-Ju Hwang, Sang-Ho Park, Chul Lee, Kwang-Jung Son, KeunHyeok Lee, HyunCheol Wang, and Nae Il Lee

Wonik IPS, Korea

FP-028

Model Predictive Control of Electron Density for Ar/SF₆ Etching Plasma

Sangwon Ryu, Hyun-Joon Roh, Yunchang Jang, Damdae Park, Junmo Koo, Jongmin Lee, and Gon-Ho Kim

Seoul Nat'l Univ., Korea

FP-029

In-Situ Monitoring Method of Plasma Process Equipment Condition: Deposition and Cleaning

Surin An, Geonji Kang, Kwangpyo Kim, and Sang Jeen Hong

Myongji Univ., Korea

FP-030

Plasma Diagnostic Method by Charging Capacitor in a Floating Langmuir Probe

Moo-Young Lee, Kyung-Hyun Kim, and Chin-Wook Chung

Hanyang Univ., Korea

FP-031

Measurement of Ion Energy Distribution According to Positive Voltage Applied to the Substrate

Dae Chul Kim, Jong-Bae Park, and Young-Woo Kim

NFRI, Korea

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The 7th International Conference on Microelectronics and Plasma Technology
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July 24–28, 2018 / Songdo ConvensiA, Incheon, Korea

FP-032

Optical Emission Spectroscopy at a Foreline for Monitoring Plasma Processes

Dae-Woong Kim, Min Hur, Jin Young Lee, Woo Seok Kang, and Jae-Ok Lee
KIMM, Korea

FP-033

Investigation of Fluorine Actinometric Coefficient in Capacitively Coupled SF₆/Ar Plasma

Ji-Won Kwon, Yunchang Jang, Sangwon Ryu, and Gon-Ho Kim
Seoul Nat'l Univ., Korea

FP-034

Withdrawn

FP-035

Experimental Observation of Charging Potentials in a Deep Trench Structure Using an Anodic Aluminum Oxide Template

Jihwan Park and Chinwook Chung
Hanyang Univ., Korea

FP-036

Microscopic Stress-Induced Retardation between Amorphous SiN_x and IZO

Nakcho Choi¹, Taekyung Yim², Yeogeon Yoon², Namsuk Roh², ByoungHo Cheong¹, and MunPyo Hong¹
¹*Korea Univ., Korea*, ²*Samsung Display Co., Ltd., Korea*

FP-037

Development of Plasma Information Based Virtual Metrology (PI-VM) for Predicting Fine Variation of SiO₂ Etching Depth

Yunchang Jang, Hyun-Joon Roh, Sangwon Ryu, Ji-Won Kwon, and Gon-Ho Kim
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ICMAP 2018

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July 24–28, 2018 / Songdo ConvensiA, Incheon, Korea

FP-038

Physicochemical Characteristic Study on the He/H₂O Plasma Jet

Jingjing Liu, Dong Chen, and Guangzhen Du
Guangzhou Univ., China

FP-039

Study of Various Cross Sections of Fluorocarbons for Plasma Modeling Applications

Dhanoj Gupta, Heechol Choi, Deuk-Chul Kwon, Mi-Young Song, and Jung-Sik Yoon
NFRI, Korea

FP-040

Measurement of Electron Scattering Cross Sections of Molecules Using Magnetized

Haeuk Pyun, Dae Chul Kim, Young Rock Choi, Yonghyun Kim, Young-Woo Kim, Yeunsoo Park, Mi-Young Song, Jung-Sik Yoon, and Hyuck Cho
NFRI, Korea

FP-041

Plasma Surface Kinetic Studies of Etch Process in Fluorocarbon Plasmas

Chang Won-Seok¹, Kwon Deuk-Chul¹, Mi-young Song¹, Dea-Chul Kim¹, Jong-Sik Kim¹, Young-woo Kim¹, Jung-Sik Yoon¹, Dong-Hun Yu², Yeong-Geun Yook³, and Yeon-Ho Im³
¹*NFRI, Korea*, ²*Kyungwon Tech Inc., Korea*, ³*Chonbuk Nat'l Univ., Korea*

FP-042

The Plasma & Chemical Property Data Management System for Plasma Modeling and Simulation

Jun-Hyoung Park, Heechul Choi, Won-Seok Chang, Deuk-Chul Kwon, and Mi-Young Song
NFRI, Korea

FP-043

Numerical Optimization of Rate Coefficients of Chemical Reactions in C₄F₈ Plasma

Sang-Young Chung, Deuk-Chul Kwon, and Mi-Young Song
NFRI, Korea

FP-044

Study on the Hysteresis during E to H Mode Transition at Low Pressure Inductively Coupled Plasma

Hyun-Ju Kang, Young-Hun Hong, and Chin-Wook Chung
Hanyang Univ., Korea

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July 24–28, 2018 / Songdo ConvensiA, Incheon, Korea

FP-045

Withdrawn

FP-046

Withdrawn

FP-047

Studies of Interfacial Microstructures and Series Resistance on Electroplated and Hot-Dipped Sn- x Cu Photovoltaic Modules

Kuan-Jen Chen, Fei-Yi Hung, Truan-Sheng Lui, and Hsu Lin
Nat'l Cheng Kung Univ., Taiwan

FP-048

Numerical Simulation and Defect Analysis of CIGS Thin Film Solar Cells Using TCAD

Sangah Lee, Jaesung Lee, Jeonghoo Jo, Ganghoo Lee, Yoojeong Lee, and Myunghun Shin
Korea Aerospace Univ., Korea

FP-049

Withdrawn

FP-050

The Effect of TiCl_4 Treatment on the Interface Roughness to the Electron Transport Layer of Perovskite Solar Cell and Their Performance.

Hai Truyen Dang, Thi Nguyen Nguyen, Sang Mo Kim, and Chung Wung Bark
Gachon Univ., Korea

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July 24-28, 2018 / Songdo Convensia, Incheon, Korea

FP-051

Study of Crystalline Siliconsolar Cells Texturing Process with SF₆ Atmospheric Pressure Plasma

Woo Jae Kim¹, Hwan Hee Lee¹, Hee Tae Kwon¹, Gi Won Shin¹, Chang Sil Yang², and Gi-Chung Kwon¹

¹Kwangwoon Univ., Korea, ²Y.I. TECH, Korea

FP-052

A Study on Crystalline Solar Cell Phosphorous Doping Using Atmospheric Pressure Plasma

Hwan Hee Lee¹, Hee Tae Kwon¹, Gi Won Shin¹, Woo Jae Kim¹, Chang Sil Yang², and Gi Chung Kwon¹

¹Kwangwoon Univ., Korea, ²Y.I. TECH Co.,Ltd, Korea

FP-053

Fabrications of Copper Oxide Based Heterojunction Thin Film Solar Cell by Using Sputtering

Dae San Lee¹, Yu Jin Kim¹, Yu sup Jung², and Kyung Hwan Kim¹

¹Gachon Univ., Korea, ²CNI Tech., Korea

FP-054

Characteristics of Perovskite Solar Cells (PSCs) Prepared with Chemical Mechanical Polished Tansparent Electrode

Sangmo Kim, He Rui, Ma Ro Kim, Dang Hai Truyen, Jeongseo Kim, Haram Lee, Seong Gwan Shin, Hyung Wook Choi, and Chung Wung Bark

Gachon Univ., Korea

FP-055

Characteristics of TCO-Less Dye-Sensitized Solar Celss Using ZnO Nanorods Grown by Hydrothermal Method

Nam-Hoon Kim¹, Seok-Jae Kim², and Yong Seob Park³

¹Chosun Univ., Korea, ²Medical Microrobot Center, Korea, ³Chosun College of Science and Tech., Korea

FP-056

Fabrication of Si Thin-Film Tandem Solar Cell on Multi-Surface Textures of Periodic Honeycomb Glass

Hyeongsik Park¹, Myunghun Shin², Anh Huy Tuan Le¹, Jaehyun Cho¹, Junhee Jung¹, Jaesung Lee², Jaehyung Lee¹, and Junsin Yi¹

¹Sungkyunkwan Univ., Korea, ²Korea Aerospace Univ., Korea

ICMAP 2018

The 7th International Conference on Microelectronics and Plasma Technology
Joint International Conference on ICMAP 2018, APCPST 2018, and ISPB 2018
July 24–28, 2018 / Songdo ConvensiA, Incheon, Korea

FP-057

Development of Phosphorus Doped Highly Conducting N-Type Nano Crystalline Silicon Film for High Efficiency Thin Film Solar Cells

Chonghoon Shin, S. M. Iftiqar, Jinjoo Park, Sangho Kim, Junhee Jung, Sungjae Bong, and Junsin Yi

Sungkyunkwan Univ., Korea

FP-058

Withdrawn

FP-059

Study on the ITO Work Function and Hole Injection Barrier in Silicon Heterojunction Solar Cells

Seongho Jeon, Woong-Kyo Oh, Youngseok Lee, Donggi Shin, Geonju Yoon, Sehyeon Kim, and Junsin Yi

Sungkyunkwan Univ., Korea

FP-060

IR-Reflective Colored Solar Cells with Transparent $\text{MgF}_2/\text{Al}_2\text{O}_3/\text{SiO}_2/\text{Al}_2\text{O}_3/\text{Ag}/\text{Al}_2\text{O}_3$ Multilayer Thin Films

Jang-Hsing Hsieh and Yi-Jin Wei

¹Ming Chi Univ. of Tech., Taiwan

FP-061

Effect Of Sb Mole Concentration on the Electrochemical Characteristics of Electrodeposited Cuprous Oxide Thin Film

Young Dae Yun, Young been Kim, Joo Sung Kim, and Hyung koun Cho

Sungkyunkwan Univ., Korea

FP-062

Surface Plasma Treatment of PEDOT-TiO₂ Composite Materials and Its Applying to Electrode in Various Devices

Sang-Hun Nam, Dong In Kim, Ji Won Lee, Jung-Honn Yu, Hyeon Jin Seo, and Jin-Hyo Boo

Sungkyunkwan Univ., Korea

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July 24-28, 2018 / Songdo ConvensiA, Incheon, Korea

FP-063

Synthesis of Nitrogen-Doped Carbon Nanowalls as Direct Methanol Fuel Cell Electrode Using Plasma Enhanced Chemical Vapor Deposition

Radwan Metwaly Elzoheiry^{1,2}, Shinsuke Mori¹, Fatemeh Bohlooli¹, Hiroki Shinkawa¹, Sho Kaneda¹, and Mahmoud Ahmed²

¹Tokyo Inst. of Tech., Japan, ²E-JUST, Egypt

FP-064

Effect of Sb Mole Concentration on the Electrochemical Characteristics of Electrodeposited Cuprous Oxide Thin Film

Young Dae Yun, Sung Hyeon Jung, Young Been Kim, Joo Sung Kim, and Hyoung Koun Cho
Sungkyunkwan Univ., Korea

FP-065

Characterization of Ablation Properties of Carbon Fiber Reinforced Composites with High Enthalpy Plasma Wind Tunnel

Philyong Oh, Jung Chul Choi, Ho Seok Kim, Bo Ram Kang, Seong Man Choi, and Bong Guen Hong

Chungbuk Nat'l Univ., Korea

FP-066

Steam-Methane Reforming in a Steam Plasma Using 2.45 GHz Microwave System

Daehyun Choi, Changhyun Cho, Hyunjae Park, Jihun Kim, and Taehyup Lho

NFRI, Korea

FP-067

Withdrawn

FP-068

Improving the Efficiency of Upconversion Material with Slot Modes in Silicon Nanoblock Arrays

Youngsoo Kim, Kihwan Moon, Young Jin Lee, Seokhyeon Hong, and Soon-Hong Kwon

Chung-Ang Univ., Korea

ICMAP 2018

The 7th International Conference on Microelectronics and Plasma Technology
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July 24–28, 2018 / Songdo ConvensiA, Incheon, Korea

FP-069

Improvement of Upconversion Process Using Metamaterial Mirror

Young Jin Lee, Kihwan Moon, and Soon-Hong Kwon
Chung-Ang Univ., Korea

FP-070

The Uniformity Optimization of La-Doped BaSnO₃ Film via Multistep Spin Coating

Yi Zhang and Jaehyeong Lee
Sungkyunkwan Univ., Korea

FP-071

Surface Fluorination of MCMB and Conductive Agent by Reactive Gas in Atmospheric Pressure Plasma and Their Applications

Seungryul Yoo, Dong Chan Seok, and Yong Ho Jung
NFRI, Korea

FP-072

A Study on the Carbon Dioxide Dry Reforming with Methane Using Atmospheric 915MHz Microwave Plasma.

ChangHyun Cho, DaeHyun Choi, HyunJae Park, and JiHun Kim
NFRI, Korea

FP-073

Intense Red-Emitting Upconversion Nanophosphors with Core/Shell/Shell Structure

A-Ra Hong¹, Kwangyeol Lee², and Ho Seong Jang¹
¹KIST, Korea, ²Korea Univ., Korea

FP-074

Optimization of UV-LED Sintering in Best Conditions of Silver Nanoparticles Ink

WonJe Oh, Donguk Kim, Soohyun Hwang, JiSu Park, Jeongin Park, and Jaehyeong Lee
Sungkyunkwan Univ., Korea

FP-075

Exploring the Correlation between MoS₂ Nanosheets and 3D Graphene-Based Nano Structures for Reversible Lithium Storage

Yoonkook Son and Jae Bok Kwak
Chosun Univ., Korea

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July 24–28, 2018 / Songdo ConvensiA, Incheon, Korea

FP-076

Withdrawn

FP-077

Numerical Studies on the Performance of the Percolation Network for Flexible Transparent Conducting Electrodes under External Deformation

Jinyoung Hwang¹, HyunA Jung¹, Sang Hyun Lee², and Hiesang Sohn³

¹Korea Aerospace Univ., Korea, ²Korea Univ., Korea, ³Kwangwoon Nat'l Univ., Korea

FP-078

Withdrawn

FP-079

Mechanical Stretchability of Screen Printed Ag Nanoparticles Electrode on Polyurethane Substrate

Jieun Lim¹, Dockyoung Lee², and Hanki Kim¹

¹Sungkyunkwan Univ., Korea, ²ELK, Korea

FP-080

Withdrawn

FP-081

DC-Driven Stretchable Light-Emitting Devices Based on Perovskite Nanocomposites

Huanyu Zhou, Yeongjun Lee, Jinwoo Park, Seung Heyon Jo, Young-Hoon Kim, and Tae-Woo Lee

Seoul Nat'l Univ., Korea

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July 24–28, 2018 / Songdo ConvensiA, Incheon, Korea

FP-082

Heterostructured Semiconductor Single-Walled Carbon Nanotube Films for Solution-Processed High-Performance Thin Film Transistors

Noh-Hwal Park and Yong-Young Noh
Dongguk Univ., Korea

FP-083

Solution-Processed Amorphous Indium-Gallium-Zinc-Oxide Thin-Film Transistors on a Flexible Plastic Substrate

Jaewook Jeong and Ikjun Jang
Chungbuk Nat'l Univ., Korea

FP-084

Low Temperature Fabricated Organic-Inorganic Hybrid Insulator for Thin Film Transistors

JeongOh Kim, JaeSeok Hur, HyeonA Kim, and JaeKyeong Jeong
Hanyang Univ., Korea

FP-085

Applying Mixed Host with Newly Synthesized P-Typehost to Phosphorescent Organic Light-Emitting Diodes for High External Quantum Efficiency and Low Efficiency Roll-Off

Jun Yeob Lee, Ha Lim Lee, and HoJung Lee
Sungkyunkwan Univ., Korea

FP-086

Highly Stretchable and Ultrasoft Silver Nanowire Embedded Electrode for Stretchable Organic Light-Emitting Diodes (SOLEDs)

Jeongho Min and Chang Su Kim
KIMS, Korea

FP-087

Reaction between Metal and Oxides

Sang Min Lee, Sang Ho Hwang, Yeong Jo Baek, In Hye Kang, Min Su Kang, Seok Jun Kang, Ye Lin Han, and Byung Seong Bae
Hoseo Univ., Korea

ICMAP 2018

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July 24-28, 2018 / Songdo ConvensiA, Incheon, Korea

FP-088

A Solution Processed Hybrid Gate Dielectric Prepared with Cross-Linkable Metal Ligand

HyeonA Kim, JeongOh Kim, JaeSeok Hur, and JaeKyeong Jeong
Hanyang Univ., Korea

FP-089

Study on Back Channel Etching of IGZO Transistor with New Titanium Alloy Source/Drain

Jinwon Bae, Jeonghyun Kim, Jaehong Jeon, Heehwan Choe, and Jong Hyun Seo
Korea Aerospace Univ., Korea

FP-090

Solution-Processed Gate Insulator for Complementary Thin Film Transistor Applications on Flexible Substrate

Hyeong Jun Cho¹, Dong-Hoon Lee¹, Eung-Kyu Park¹, Min Su Kim¹, So Young Lee¹, Kee Chan Park², Heehwan Choe³, Jae-Hong Jeon³, and Yong-Sang Kim¹

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FP-091

Improved Contact Property IZO Thin-Film Transistors via Ultrathin Al₂O₃ Layer in Low Temperature Process

Hyung Koun Cho, Sung Hyeon Jung, and Cheol Hyoun Ahn
Sungkyunkwan Univ., Korea

FP-092

Promotion of Adhesion between Metal Electrodes and Stretchable Substrates Using Organic Primer

Yong Hee Kim, Eun Kwang Lee, and Joon Hak Oh
POSTECH, Korea

FP-093

Charge Mobility and Stretchability of Field-Effect Transistors Based on Semiconducting Polymers with Non-Conjugated Backbone Segments

Mingyuan Pei, Min Ju Cho², Donghoon Choi², and Hoichang Yang¹
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July 24–28, 2018 / Songdo ConvensiA, Incheon, Korea

FP-094

Neutral Beam Assisted Sputtering Gas Barrier for Stretchable Display

SeungMin Shin, YunSung Jang, Seungjun Yi, and MunPyo Hong
Korea Univ., Korea

FP-095

Study on Wet Etching Behavior of Amorphous CuZr Thin Film in Hydrogen Peroxide Solution for Stretchable Display

Jinwon Bae, Myeongsik Im, and JongHyun Seo
Korea Aerospace Univ., Korea

FP-096

Self-Alignment of Conductive Micro-Sphere for Stretchable Micro LED

Ho Won Yoon, Jae Byung Park, and MunPyo Hong
Korea Univ., Korea

FP-097

Enhanced Electrical and Physical Properties of Metal Nanowire Networks Using Inductive Coil System

Jisoo Oh and Geunyoung Yeom
Sungkyunkwan Univ., Korea

FP-098

Free-Standing Stretchable Sensor Array Using Stiffness Design of Interconnectors

Jongho Lee and Namyun Kim
GIST, Korea

FP-099

Fabrication of Flexible Ag Circuit at Low Temperature Using Intense Pulsed Light Energy

SangWoo Kim¹, JongWoong Kim², Dong-Gun Kam³, and SeungBoo Jung¹
¹*Sungkyunkwan Univ., Korea*, ²*Chonbuk Nat'l Univ., Korea*, ³*Ajou Univ., Korea*

FP-100

Large-Scale Etching of Silicon Nitride Using a Linear ECR Plasma Source with Reciprocating Substrate Motion

SeongYong Kwon, HoWon Yoon, YunSung Jang, SeungMin Shin, Seungjun Yi, and MunPyo Hong
Korea Univ., Korea